

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	47	isolation and ((shallow and deep) near trench\$2) and recess\$3 and ((first and second) with (polishing or CMP))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:08
L3	245	isolation and ((shallow and deep) near trench\$2) and recess\$3 and (polysilicon with fill\$3)and (polishing or CMP)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:11
L4	1	(isolation and ((shallow and deep) near trench\$2) and recess\$3 and (polysilicon with fill\$3)and (polishing or CMP)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:11
L5	94	3 and (silicon near (oxide and nitride)) and mask	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:12
L6	7648	438/221,222,296,359-361, 424-450.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:23
L7	41	6 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:23
L8	32	(chang-kuan-lun or liu-ruey-hsin or lioutsyr-shyang or chiang-chih-min or tsai-jun-lin).in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:25
L9	85	"6214696" "5895253" "6232043" "6194287" "6255184" "6110794"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:26

L10	7	9 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/13 13:26
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